E ect of m icrostructures on the electron-phonon interaction in the disordered m etals $P d_{60} A q_{40}$

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U sing the weak-localization m ethod, we have measured the electron-phonon scattering times $_{\rm ep}$ in Pd $_{60}$ A g_{40} thick $\,$ lms prepared by DC- and RF-sputtering deposition techniques. In both series of samples, we $\,$ nd an anomalous $1=_{\rm ep}$ / T 2 'temperature and disorder dependence, where 'is the electron elastic mean free path. This anomalous behavior cannot be explained in terms of the current concepts for the electron-phonon interaction in impure conductors. Our result also reveals that the strength of the electron-phonon coupling is much stronger in the DC than RF sputtered $\,$ lms, suggesting that the electron-phonon interaction not only is sensitive to the total level of disorder but also is sensitive to the microscopic quality of the disorder.

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I. INTRODUCTION

The electron-phonon (e-ph) scattering time, ep, is one of the most important physical quantities in metals and superconductors. For instance, it determ ines the dephasing (also called the phase-breaking or decoherence) time for the electron wave function, the cooling time for an electron gas, and the relaxation time for the order param eter in a superconductor. The e-ph scattering time also plays a crucial role in the developm ent of novelm esoscopic devices such as sensitive low-tem perature bolom eters [1]. The e-ph scattering time in the presence of multiple (elastic) impurity scattering has been intensively calculated by several authors [2, 3, 4], but the current understanding of the temperature and electron elastic m ean free path, ', dependences of ep is still in complete. In particular, di erent tem perature and disorder dependences of ep have been reported, both theoretically and experim entally [5, 6]. Recently, it was proposed that, in addition to the dependence on the total level of disorder, the T and 'dependence of ep might be fairly sensitive to the microscopic quality of the disorder [7, 8, 9]. It has also been conjectured that the contribution due to the Um klapp process of impurity scattering may be important [10].

In this work, we have fabricated two series of $Pd_{60}Ag_{40}$ thick Ims by DC-sputtering and RF-sputtering deposition techniques. The palladium-silver alloys are chosen because Pd and Ag form perfect foc solid solution through the alloy series [11]. Also, since the masses of the Pd and Ag atoms are quite similar, the vibrational spectrum of the lattice does not change signicantly through the alloy series [12]. The low-eld magnetoresistances of our Ims are measured at liquid-helium temperatures, and

are compared with the weak-localization theoretical predictions to extract the values of the e-ph scattering time. Our results for the temperature and electron mean free path dependence of $_{\rm ep}$ and their implications are described below .

II. EXPERIM ENTAL M ETHOD

In s were prepared from a 99.995% pure Pd₆₀Ag₄₀ (hereafter referred to as PdAg) target. Two series of thick Im swere fabricated, one by DC-sputtering and the other by RF-sputtering deposition technique. The Ims were deposited onto glass substrates held at room tem perature. In both cases, a background pressure 10 6 torrwas reached before an argon atm osphere of 3:8 10 3 torrwas introduced to initiate the deposition process. A same sputtering gun was used for these two deposition methods, but with the gun being connected to either a DC or a RF power supply. The distance between the sputtering target and the glass substrates was the same for both methods. The sputtering power was progressively adjusted to \tune" the deposition rate, which resulted in di erent amounts of disorder, i.e., the residual resistivities $_0 \models (10 \text{ K})$], in the lm s. For the DC-sputtering (RF-sputtering) case, the deposition rate was varied from 30 to 230 (19 to 333) A/m in, and values of $_{0}$ ranging from 281 to 183 (74 to 178) obtained.

The sample structures of our Imswere carefully studied by performing the powder diraction on an MAC MXP18 x-ray diractometer. The x-ray power was 10 kW and the scanning speed was 6 degrees per minute. In all cases, we found our samples to reveal very similar diraction patterns, which clearly suggested that both the DC and RF sputtered Ims possessed the same for lattice structure characteristic to that of the PdAg alloys. Representative x-ray diraction patterns for two DC and

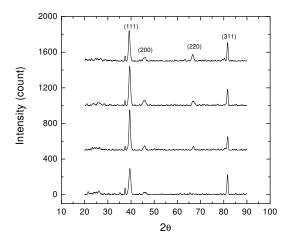


FIG. 1: X-ray di raction patterns for two DC (top two curves) and two RF (bottom two curves) sputtered PdAg thick lms. The sample resistivities (300 K) from top down are 189, 82, 79, and 132 $\,$ cm. The di raction intensity shows an arbitrary unit.

two RF sputtered Ims are shown in Fig. 1.

Most of our Ims had a thickness t & 4000 A. This thickness ensured that the weak-localization e ects were three-dimensional in our samples. It also ensured that the thermal phonons were unambiguously three-dimensional, i.e., the wavelength of the most probable thermalphonons was always smaller than the Im thickness at our measurement temperatures. This latter condition greatly eliminated any complications that might result from phonon con nement e ects. (In reduced-dimensional systems, modications to the phonon spectrum and the speed of sound might be signicant, which could lead to non-straightforward temperature and disorder behavior of ep.)

Our values of the di usion constant, D , were evaluated through the E instein relation $_0^{-1}=$ D e^2N (0)=(1+), where N (0) is the electronic density of states at the Fermi level, and is the e-ph m assenhancement factor. The values of N (0) were calculated from the independently determined electronic special cheat: T = $\frac{1}{3}$ $^2k_B^2N$ (0)T. For Pd $_{60}A$ g $_{40}$, '0.43, and '3.3 m J/m ol K 2 [11]. Then, we obtained D (100= $_0$) cm 2 /s, where $_0$ is in cm. Table I lists the values of the relevant parameters for our lms studied in this work.

III. RESULTS AND DISCUSSION

The normalized magnetoresistivities, 4 (B) = 2 (0) = [(B) (0)] = 2 (0), for the PdAg17 thick lm at several temperatures are plotted in Fig. 2. The symbols are the experimental data and the solid curves are the three-dimensional weak-localization theoretical predictions [13]. It is clearly seen that the weak-localization

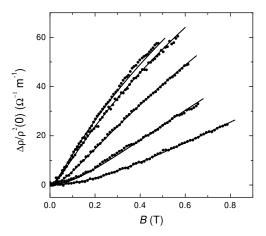


FIG. 2: Normalized magnetoresistivities as a function of magnetic eld for the PdA g17 thick. In at (from top down) 1.0, 3.0, 6.0, 9.0, and 14.0 K. The solid curves are the three-dimensional weak-localization theoretical predictions.

predictions can describe well our experimental data. Therefore, the electron dephasing time , which is the key parameter in the weak-localization theory, can be reliably extracted. Since PdAg has a very strong spinorbit scattering, is the only adjusting parameter in the comparison of the theory with experiment. (That the spin-orbit scattering is strong in PdAg is evident in the shape of the positive magnetoresistivity curves shown in Fig. 2.) The details of our data analysis procedure was discussed previously [14].

In three dim ensions, the total electron dephasing rate that governs the weak-localization e ects is given by [13]

$$\frac{1}{(T; ')} = \frac{1}{(0)} + \frac{1}{(0)}; \qquad (1)$$

where 0 = (T ! 0) depends very weakly on temperature, if at all, and is called the saturated dephasing time. Whether 0 should reach a nite or an in nite value as T ! 0 is currently under vigorous experimental and theoretical investigations [6]. At nite temperatures, the dominating inelastic electron process in three dimensions is solely due to the e-ph scattering, while the Nyquist electron-electron scattering is negligibly small [6, 15, 16]. U sually, one writes $1 = _{\rm ep} = A_{\rm ep}T^{\rm p}$ over the limited temperature range accessible in a typical experiment, where $A_{\rm ep}$ characterizes the strength of the e-ph coupling, and p is an elective exponent of temperature. A coording to current understanding, p lies between 2 and 4 [2, 3, 4, 9].

The extracted (T) between 0.5 and 20 K for each of our lms is least-squares tted to Eq. (1), and the tted values of the relevant parameters (0 , $A_{\rm ep}$, and p) are listed in Table I. Figure 3 shows a plot of the variation of 1= with temperature for the PdA g17 thick lm. The symbols are the experimental data. The thick solid curve drawn through the data points is obtained with 0 ,

TABLE I: Values of the relevant parameters for Pd $_{60}$ Ag $_{40}$ thick lms. The samples end with (without) an dagger denote lms prepared by DC-(RF-) sputtering deposition technique. t is the lm thickness. $_0$ is the resistivity at 10 K.D is the direction coecient. The values of k_F '= 3mD=~ are computed by assuming the free electron mass of m, where k_F is the Fermiwave number. 0 is the tted electron dephasing time as T! 0. A_{ep} and p are the tted strength of e-ph coupling and electron exponent of temperature, respectively, in $1=_{ep}=A_{ep}T^P$.

Sample	t (A)	0 (cm)	D (cm ² /s)	k _F '	⁰ (10 ¹⁰ s)	A_{ep} (10^8 s ¹ K ^p)	р
PdAg11 ^y	3900	281	0.36	0.93	2.8	1.5	2.3 0.1
P dA g15 ^y	5100	235	0.43	1.1	1.1	2.4	1.9 0.2
P dA g08 ^y	3900	224	0.45	1.2	6.7	2.0	2.4 0.1
P dA g12 ^y	4800	183	0.55	1.4	3.7	2.8	2.2 0.1
PdAg18	5000	178	0.56	1.5	4.3	0.40	2.4 0.1
PdAg17	4500	101	0.99	2 . 6	1.6	2.2	2.2 0.1
PdAg19	4000	98	1.0	2 . 6	1.6	2.9	2.3 0.1
PdAg14	4100	90	1.1	2.9	1.1	2.5	2.2 0.2
PdAg16	3300	74	1.3	3.5	0 . 97	3.6	22 01

A $_{\rm ep}$, and p as free parameters. In this case, we obtain a tem perature exponent p = $2\,2$ 0.1. For comparison, we have also least-squares the them easured 1= with Eq. (1), but with p xed at an integer value of either 2, 3, or 4 (while allowing of and A $_{\rm ep}$ to vary). The dotted, dashed, and thin solid curves in Fig. 3 plot the the temperature with p = 2, 3, and 4, respectively. It is clearly seen that our temperature dependence of 1= $_{\rm ep}$ can be best described with an exponent p equal or close to 2. In fact, we have found that the temperature behavior of $_{\rm ep}$ for all Ims listed in Table I is very similar, i.e., 1= $_{\rm ep}$ demonstrates an essentially quadratic temperature dependence.

Inspection of Table I indicates that, for either DC or RF sputtered $\,$ Im s, the value of $A_{\rm ep}$ decreases with increasing level of disorder ($_0$) in the sample. Figure 4 plots the $\;\;$ tted A_{ep} as a function of the di usion constant. C learly, ones sees that A $_{\rm ep}\,$ varies linearly with D , im plying that 1= $_{
m ep}$ / D / '. It should be noted that, if we plot 1 = ep as a function of the measured 0, we also observe a linear variation, i.e., $1 = ep / 0^{1} / 1$. Such a linearity of A_{ep} with 'holds for both series of lm s. Quantitatively, however, the values of A_{ep} (for a given disorder) for the DC and RF sputtered Ims are very di erent. For exam ple, while the DC sputtered PdAg12 and the RF sputtered PdAg18 thick Ims have essentially the same $_{0}$, their values of A_{ep} di er by several times. Moreover, Fig. 4 reveals that the slope of the linearity is about a factor of 2 larger in the DC than RF sputtered Ims. Since the x-ray di raction studies dem onstrate that the crystal structures are quite sim ilar for both series of lms (Fig. 1), the di erences in the values of A_{ep} and the variation of A_{ep} with 'strongly in ply that the e-ph interaction must be very sensitive to the m icrostructures of the sam ples. The subtle di erence in the microstructures in these two series of Imsmay result from the di erent ways of sample preparation.

Taken together, Fig. 3 and Fig. 4 demonstrate that the e-ph scattering in PdAg possesses an anom alous temperature and disorder dependence of $1=_{\rm ep}$ / T^2 '. This dependence is insensitive to the fabrication method. Such

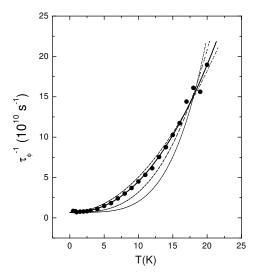


FIG. 3: Electron dephasing rate as a function of temperature for the PdA g17 thick lm. The thick solid curve drawn through the data points is a least-squares to Eq. (1), using p as a free parameter. The dotted, dashed, and thin solid curves are least-squares to Eq. (1) with p xed at 2, 3, and 4, respectively (see text).

a T² behavior is totally unexpected, even qualitatively, in terms of the current theoretical concepts for the e-ph interaction in impure conductors. A coording to the \orthodox" e-ph interaction theory for disordered m etals [2, 3, 4], that assumes a coherent motion of the impurity atoms with the deformed lattice atoms at low temperatures, one should expect a T⁴ dependence. Recently, it was speculated that, in real metals containing heavy (light) impurities and tough boundaries, the impurity and/or boundary atoms might not move in phase with the lattice atoms [7]. The rst calculations in considera-

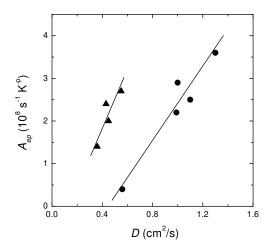


FIG. 4: The strength of e-ph coupling $A_{\rm ep}$ as a function of di usion constant for DC (triangles) and RF (circles) sputtered PdAg thick lm s. The straight lines drawn through the data points are quides to the eye.

tion of this e ect have been done by Sergeev and M itin [9]. They found that even a small amount of \static" potential scatterers drastically changes the e-ph-im purity interference, and the relaxation rate is proportional to T²L ¹, where L is the electron mean free path with respect to the static im purities (L '). Experim entally, a T⁴ tem perature dependence has been observed very recently in disordered H fand Tithin lm s [1]. (A T^4 dependence had been previously observed in Bithin Ims over a very limited tem perature range of 0.6 12 K [17].) However, to the best of the authors' know ledge, the combined T4 law has never been con med in real conduc-dence has been observed in T i_4 $_x$ A l_x [7] and T i_4 $_x$ Sn $_x$ alloys [8]. Previously, a T2 dependence was independently found in AuPd thick Ims (t & 4000 A) [15], and

Nb thin lms (t. 200A) [18]. In the present case of PdAg thick lms, the masses of the Pd and Ag atoms are quite similar, and the lms are three-dimensional. Therefore, it is not clear how the Sergeev-M it in theory evoking heavy (light) impurities and tough boundaries can apply to this case.

The criterion for the e-ph interaction to satisfy the dirty-lim it condition is q_T ' 1, where the wave num ber of the therm alphonons q_T $k_B T = v_s$, and v_s is the $2600 \, \text{m/s} [19] \, \text{and} \, \, \, \, \, \,$ speed of sound. Taking vs $(0.01 \quad 0.04)$ T pfor our PdA g thick A, we obtain q_T T lm s. The phase-breaking lengths D in our are calculated to be 690 1500A at 2 K. (The dephasing length essentially saturates below about 2 K.) This length scale justi es the use of three-dim ensional weaklocalization theory to describe our experim ental magnetoresistivities.

IV. CONCLUSION

We have measured the e-ph scattering time $_{\rm ep}$ in DC and RF sputtered PdAg thick $_{\rm ms}$. In both series of $_{\rm ms}$, we observe an anomalous $_{\rm ep}$ / $_{\rm T}$ 'tem perature and disorder dependence. Moreover, the e-ph coupling is found to be much stronger in the DC than RF sputtered $_{\rm ms}$. This observation strongly indicates that the e-ph interaction not only is sensitive to the total level of disorder but also is sensitive to the microscopic quality of the disorder. These results pose a new theoretical challenge.

A cknow ledgm ents

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